



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Martin, et al.

Confirmation No.: 1603

Serial No.: 09/855,972

Group Art Unit: 1763

Filed: May 15, 2001

Examiner: Hassanzadeh, Parvis

Docket No. 062002-1751

For: **Method and Apparatus for Low Energy Electron Enhanced Etching of Substrates in an AC or DC Plasma Environment**

AMENDMENT AFTER ALLOWANCE

Mail Stop Issue Fee
P.O. Box 1450
Commissioner for Patents
Alexandria, Virginia 22313-1450

Sir:

Pursuant to 37 C.F.R. 1.312, please enter the following amendments. Applicants respectfully submit that the amendments herein merely embody the correction of formal matters and do not alter the scope or substance of the application.

It is not believed that extensions of time or fees for net addition of claims are required, beyond those, which may otherwise be provided for in documents accompanying this paper. However, in the event that additional extensions of time are necessary to allow consideration of this paper, such extensions are hereby petitioned under 37 C.F.R. § 1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to deposit account no. 20-0778.